Mo Tu We Th Fr Sa Su Date:
GaAS Al Ga AS
$E_g(x) = 1.425 + 1.155x + 0.37x^2 \Rightarrow 8 \text{ harpes}$
$E_g^{X}(x) = 1.911 + 0.005x + 0.37x^2$
$E_g(x) = 1.734 + 0.574 \times + 0.055 \times^2$
Telas think
mi = 0.082 m i = 100
T-X crossover occurs in the
Γ-X crossover occurs in the compositional range of 0.4≤x≤0.5
This energy gap is also T dependent.
This energy gap is also T dependent.  An empirical equation is given by
$E_{i}(T) = \frac{E_{io} - \lambda T}{(T+\beta)}$
$(T+\beta)$
a party and hearth belief chart in his party
where Eio = 1.519 eV
d = 5.405 × 10 4 eV/K
where $E_{io} = 1.519 \text{ eV}$ $d = 5.405 \times 10^{-4} \text{ eV/k}$ $\beta = 204 \text{ K}$
for 02T21000K
It has a graduatic dependence on temp.
It has a graduatic dependence on temp. for small T, changing towards a linear dependence for T >>B.
dependence for T +B.

The curvature dE is + re at the

conduction band minima, but is -ve at the valence band maxima. Thus the electrons near the top of the valence band have -ve effective mass, according to

 $m^* = \frac{5^2}{d^2 E/dk^2}$ 

Valunce band electrons with -ve charge and -ve mass move in an electric field in the same direction as holes with +ve charge and +ve mass.

a loosely bound fifth electron as ranging about the righty bound core electrons constitutes a hydrogen like orbit.

Hence for n=1  $E = m_n q$ 

where  $K = 4 \pi \epsilon_0 \epsilon_r$ 

$$h = \frac{h}{2x}$$

$$\Rightarrow E = \frac{8(\epsilon_0 \epsilon_r)^2 h^2}{8(\epsilon_0 \epsilon_r)^2 h^2}$$

$$m_n^* = 0.067 \times m_0 = 0.067 \times 9.11 \times 10^{-31} \text{ kg}$$
 $9 = 1.6 \times 10^{-19} \text{ J}$ 
 $6 = 8.85 \times 10^{-12}$ 

divide it by of, That gives energy in ev

----- 0.0052 eV

ii) Column II impurities replacing column III slements serve as acceptors Be, Zn, Cd

iii) Si or Ge replacing Ga - donor Si or Ge replacing As - acceptor

Called "amphoteric" impurity

Of we dope Si with 10 As atoms/cm³, The conduction electron concentration changes from 10'0 cm³ to 10'5 cm³ => 5 orders of magnitude

The registivity of Si changes from about 2×10<sup>5</sup> Ω-cm to 5 Ω-cm into this doping.

